

NS6130-10-1191

TIN Sputtering Target

Quick Facts

Product	:	Tin Sputtering Target
Stock No	:	NS6130-10-1191
CAS	:	7440-31-5
Purity	:	99.99%
Molecular Formula	:	Sn

Technical Specification

Diameter	Thickness	Molecular Weight
50.8 mm ± 1mm	3 mm ± 0.5mm	118.71 g/mol

Tin sputtering targets are commonly used in a variety of applications, including the manufacture of electronic components such as thin-film transistors (TFTs), solar cells, and flat panel displays. They are also used in the production of decorative coatings, as well as in the automotive and aerospace industries.



* This image is for graphic purposes only and does not represent the actual product.

